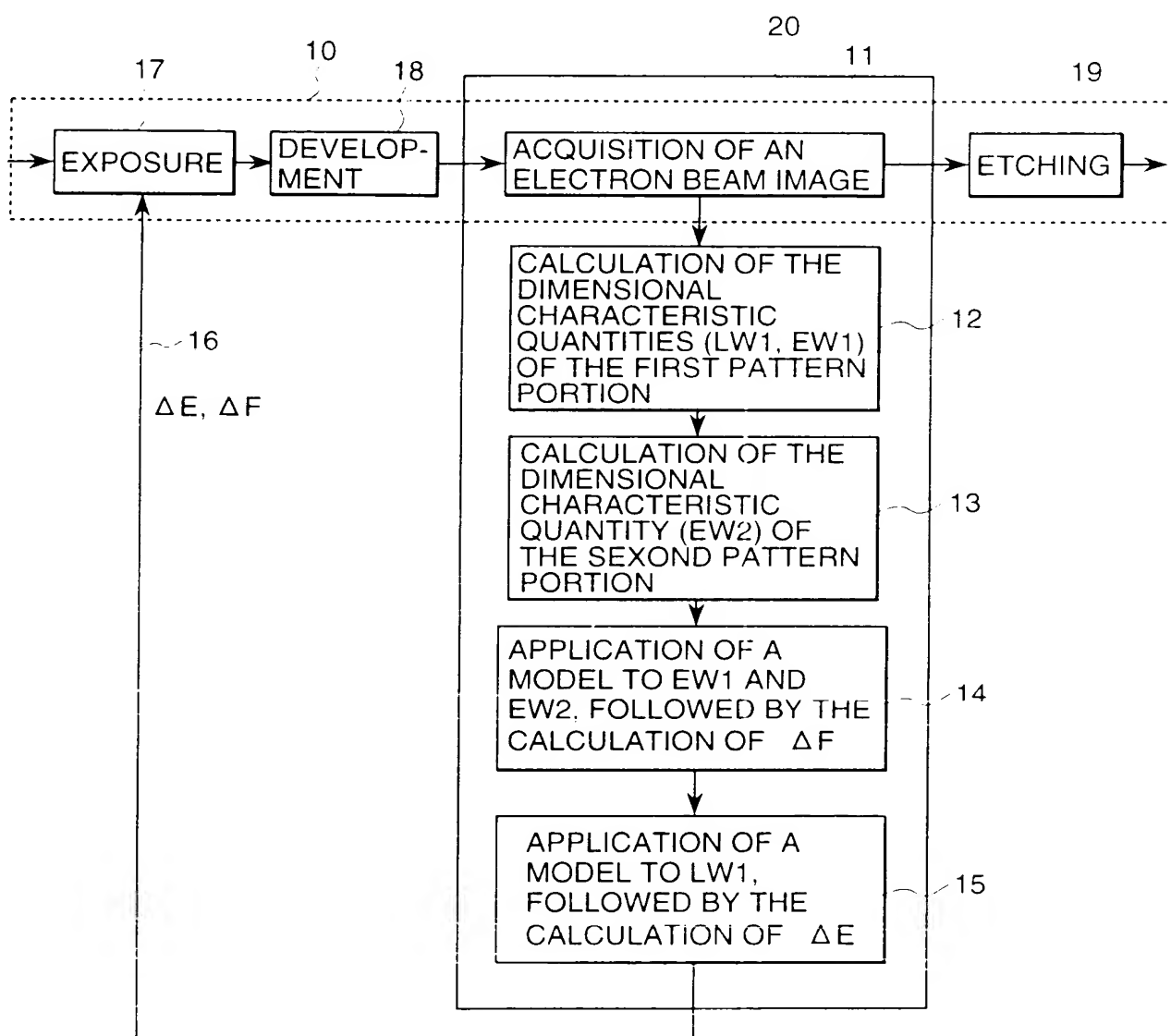


FIG. 1



LW : LINE WIDTH
EW : EDGE WIDTH

FIG. 2

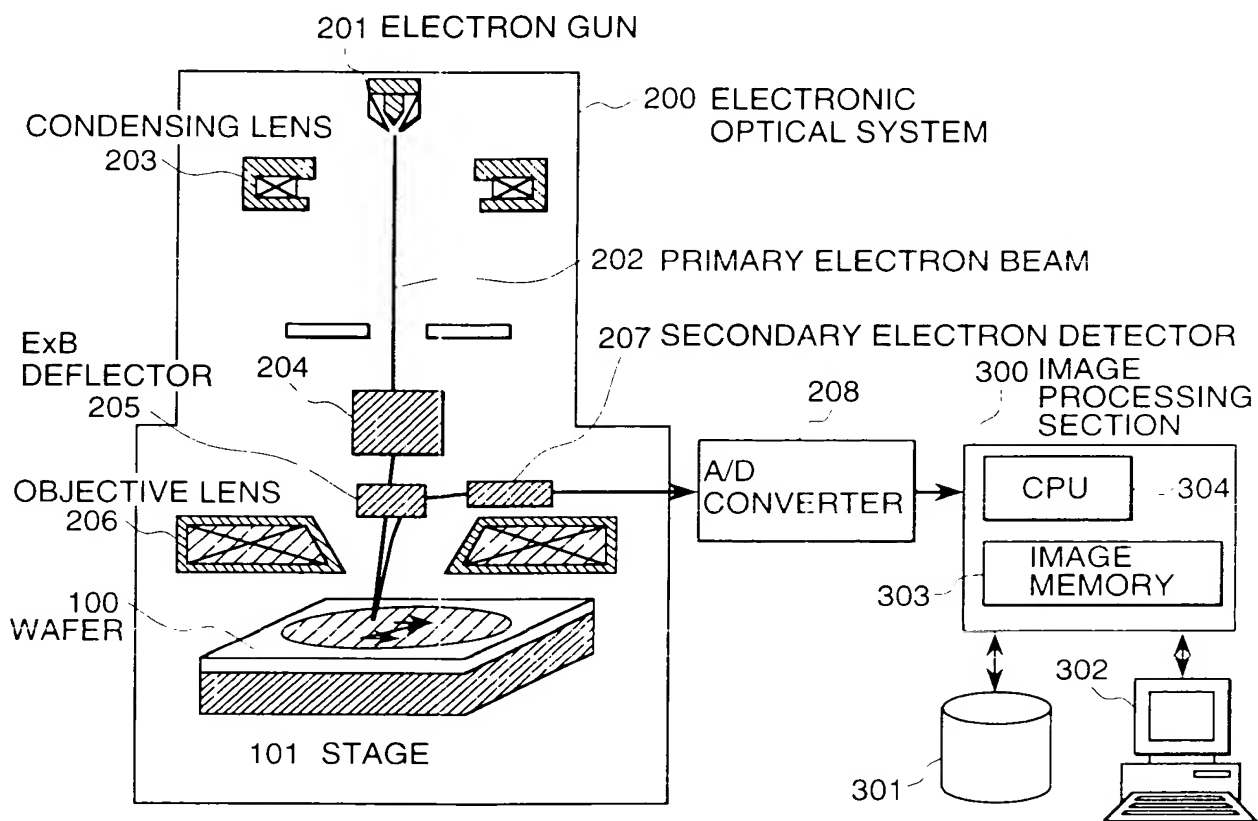


FIG. 3

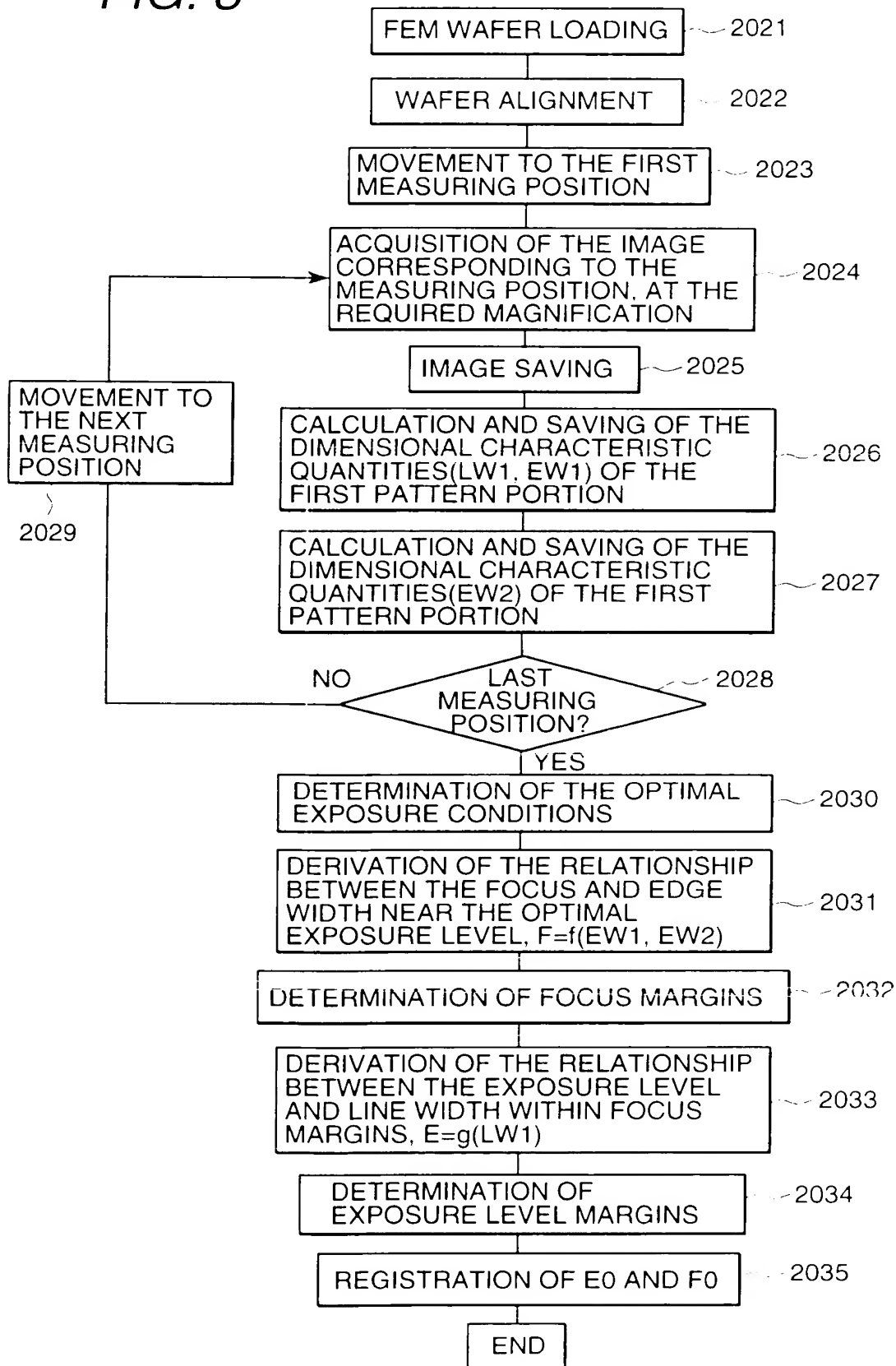


FIG. 4(a)

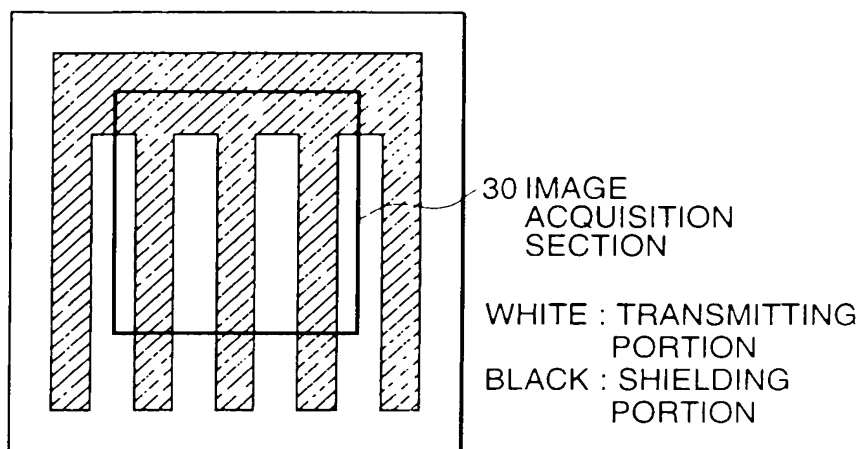


FIG. 4(b)

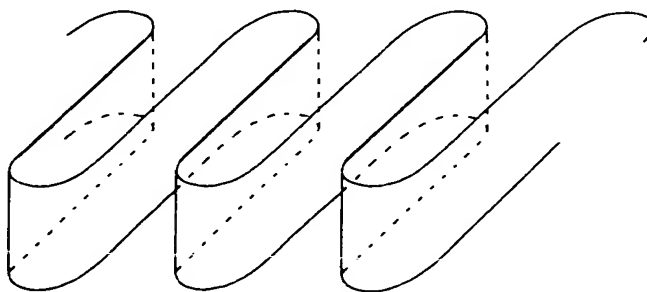


FIG. 4(c)

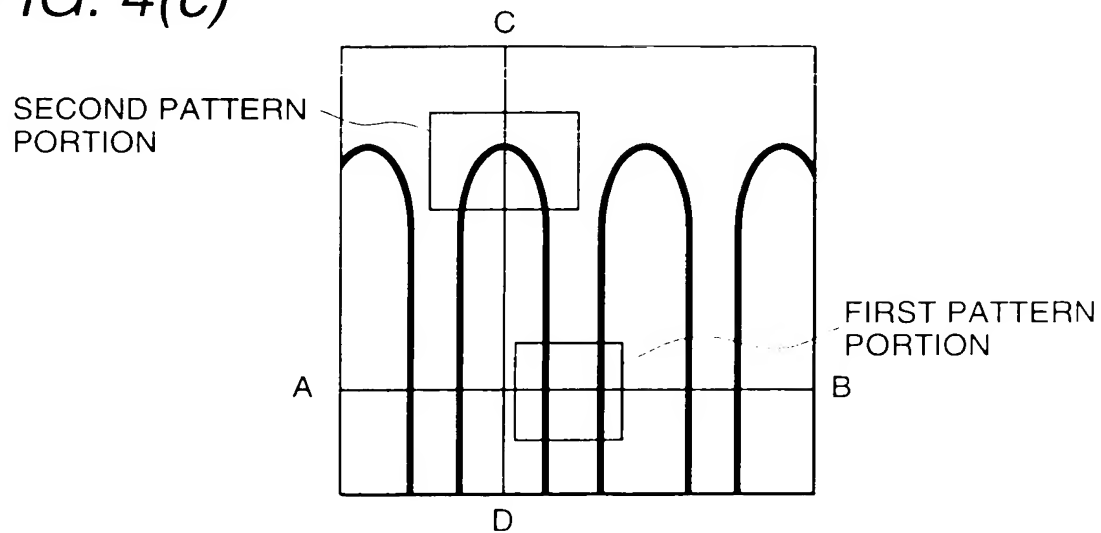


FIG. 5(a)

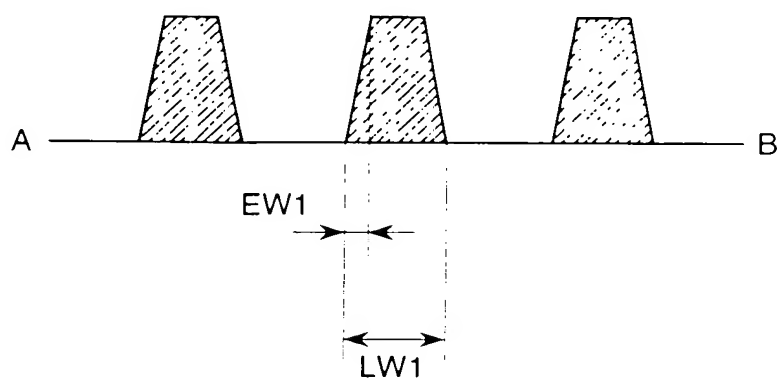


FIG. 5(b)

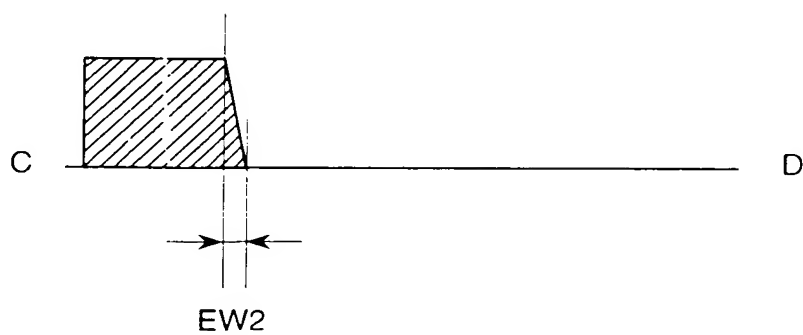


FIG. 5(c)

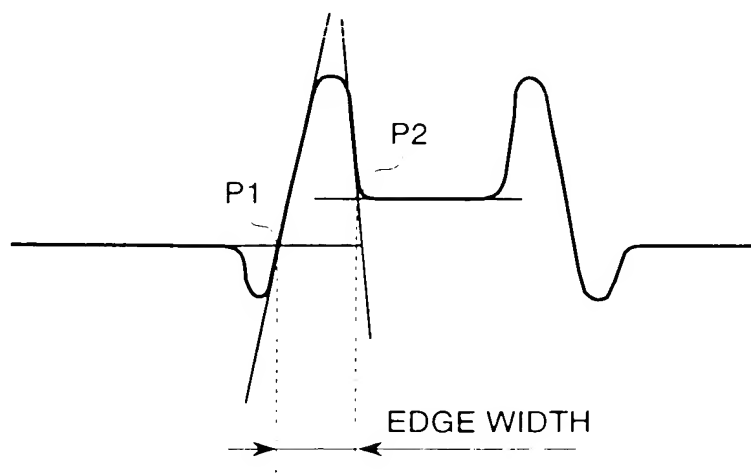


FIG. 6(a)

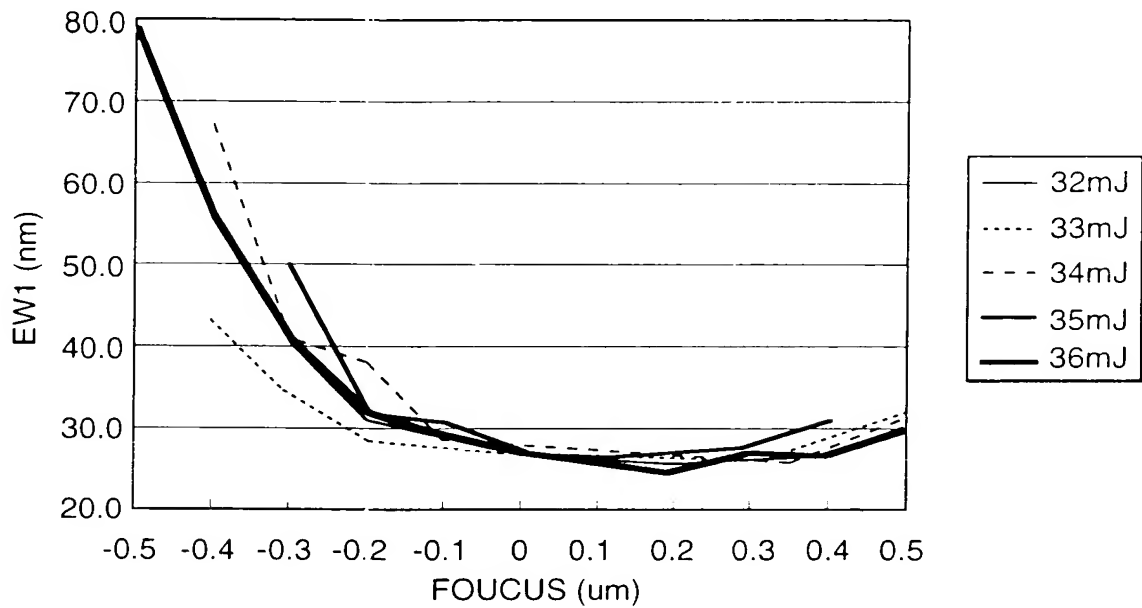


FIG. 6(b)

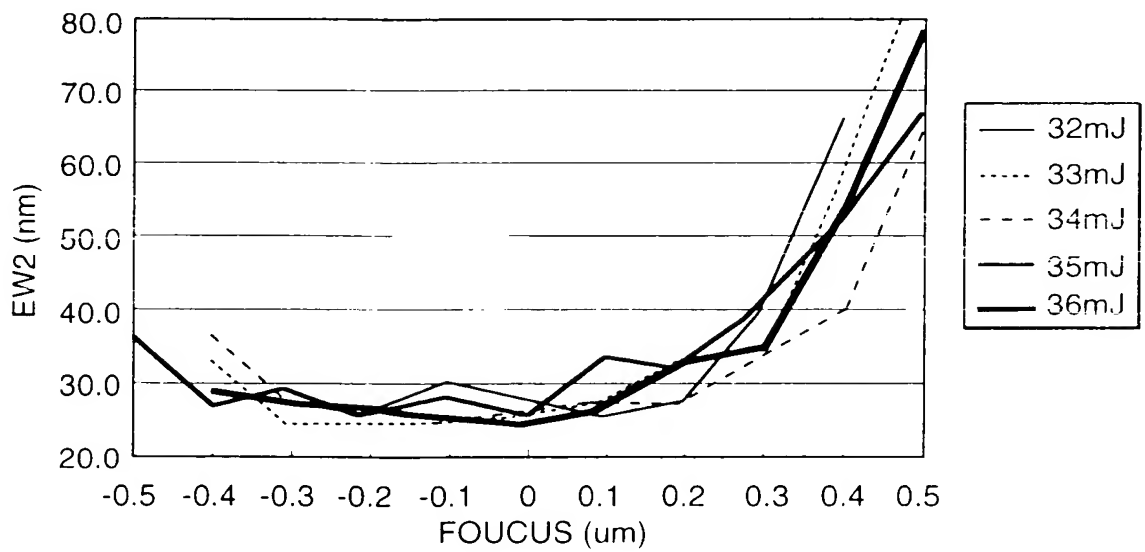


FIG. 17(a)

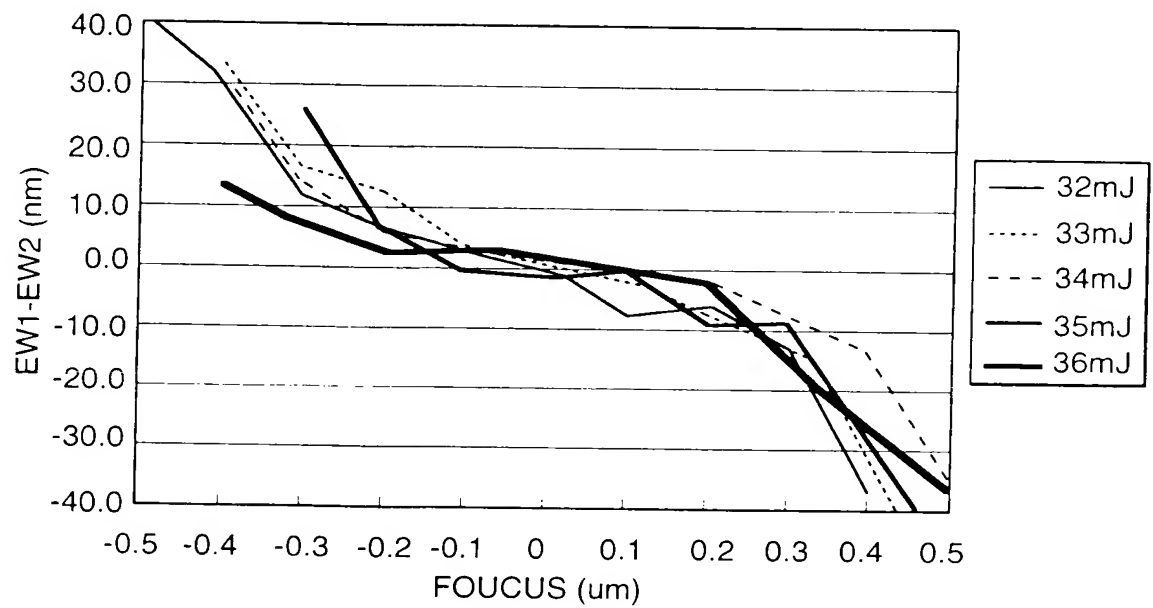


FIG. 17(b)

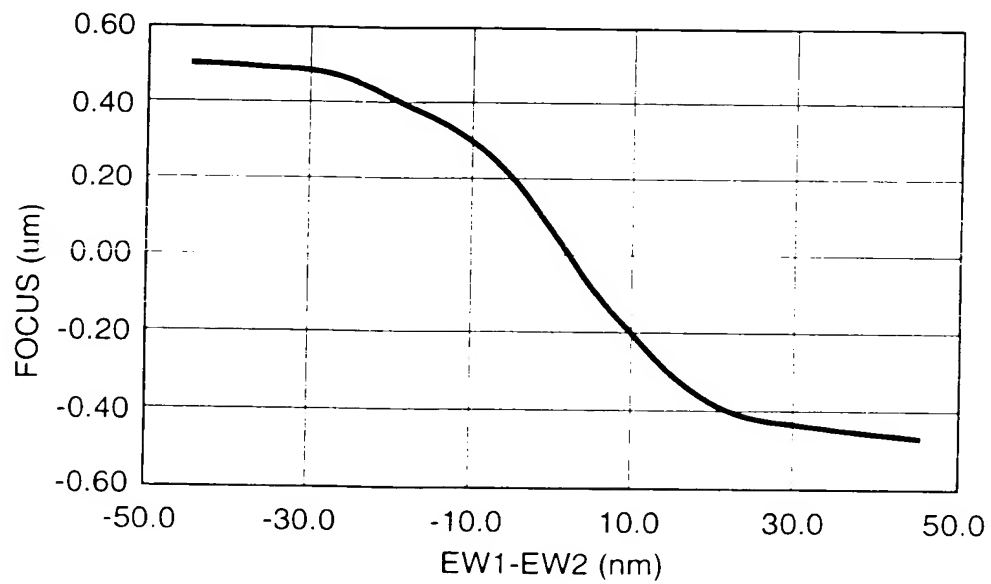


FIG. 8

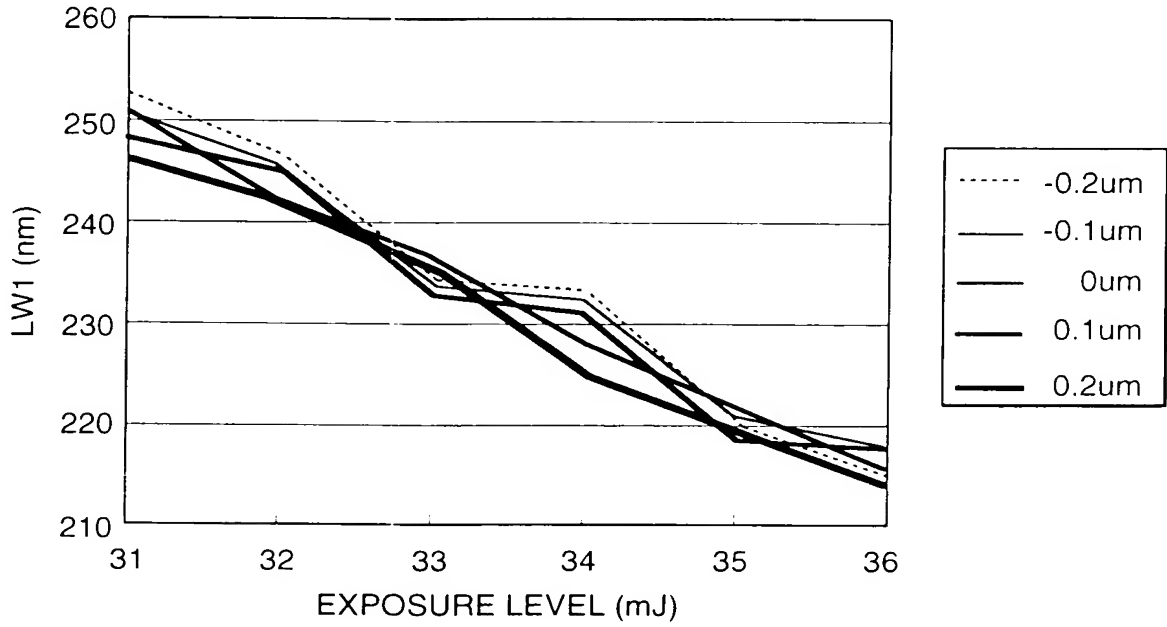


FIG. 11


[illegible]

FIG. 9(a)

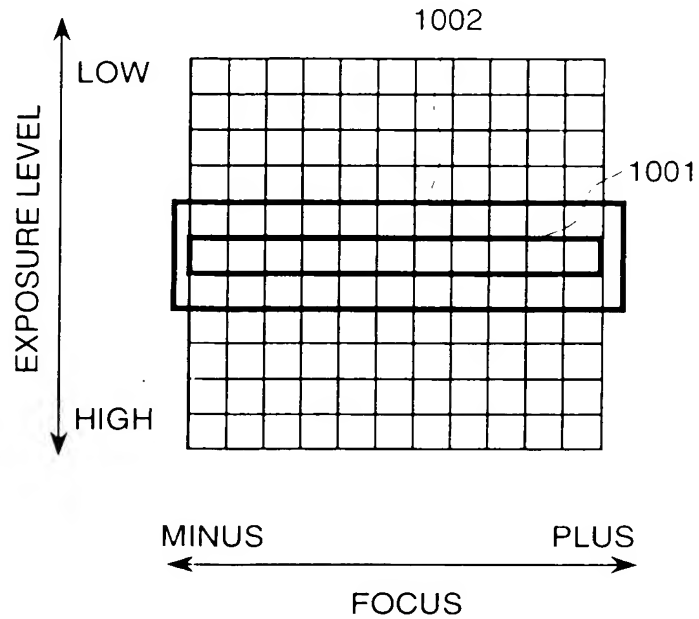


FIG. 9(b)

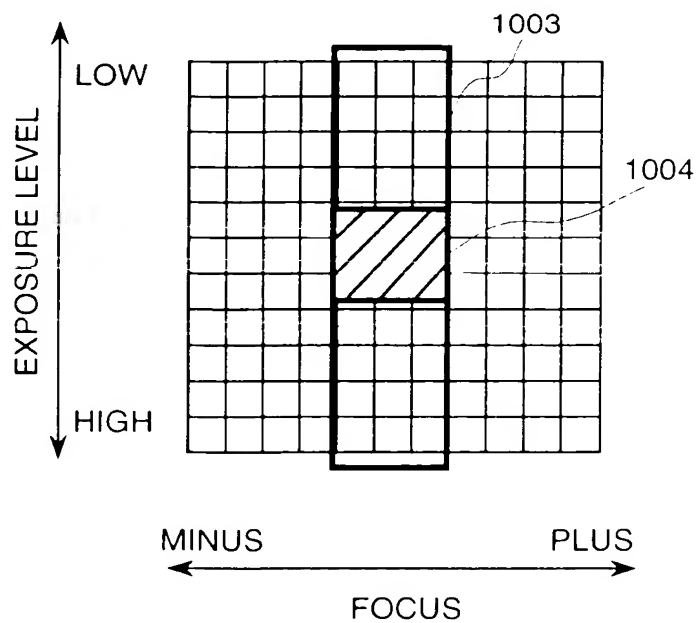


FIG. 10

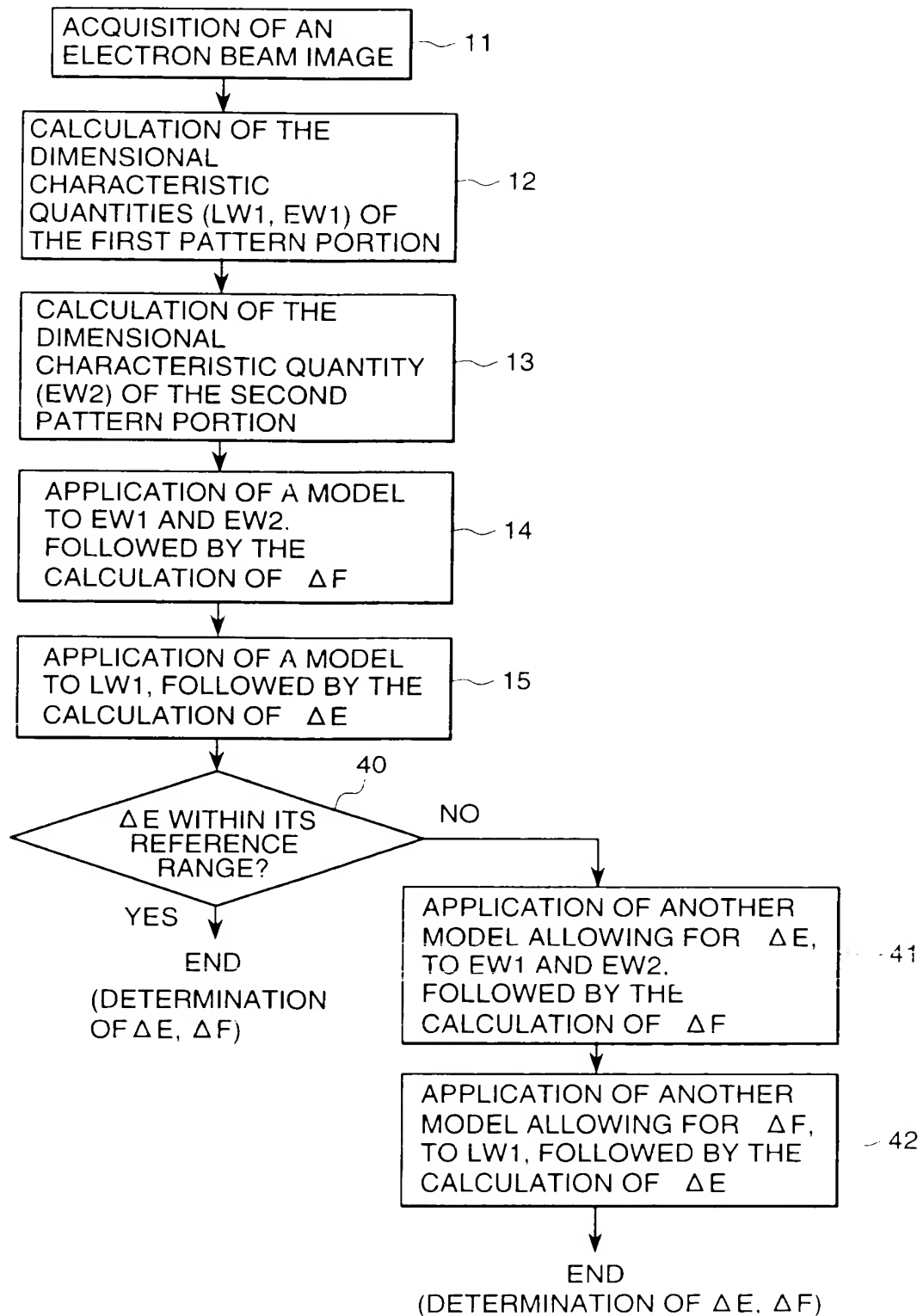


FIG. 12(a)

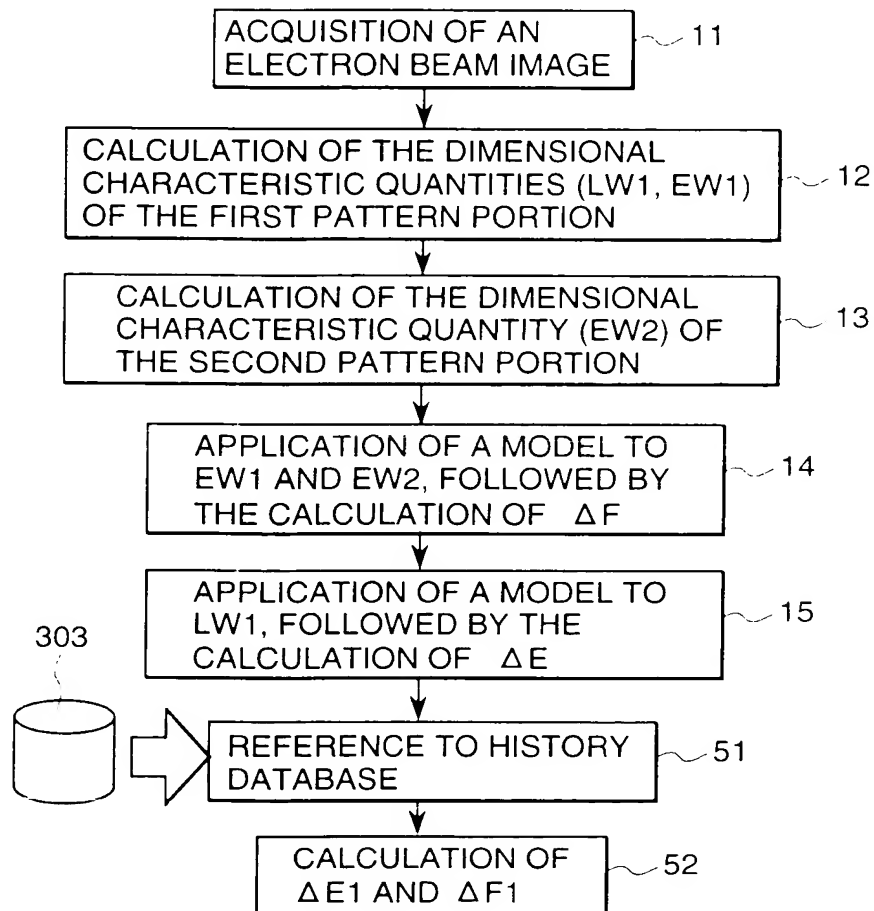


FIG. 12(b)

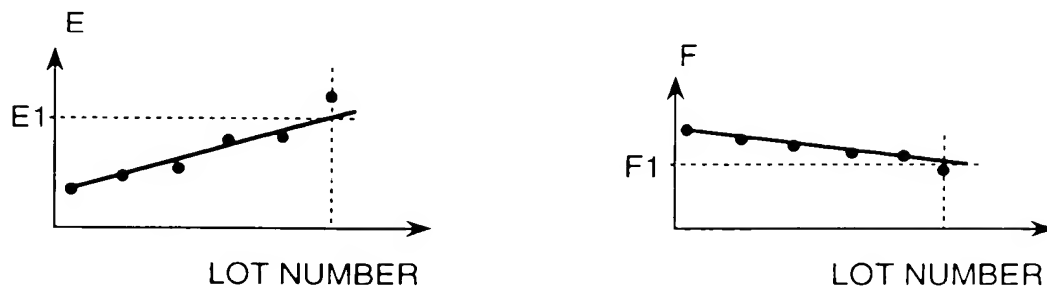


FIG. 13(a)

WHITE: TRANSMITTING PORTION
BLACK: SHIELDING PORTION

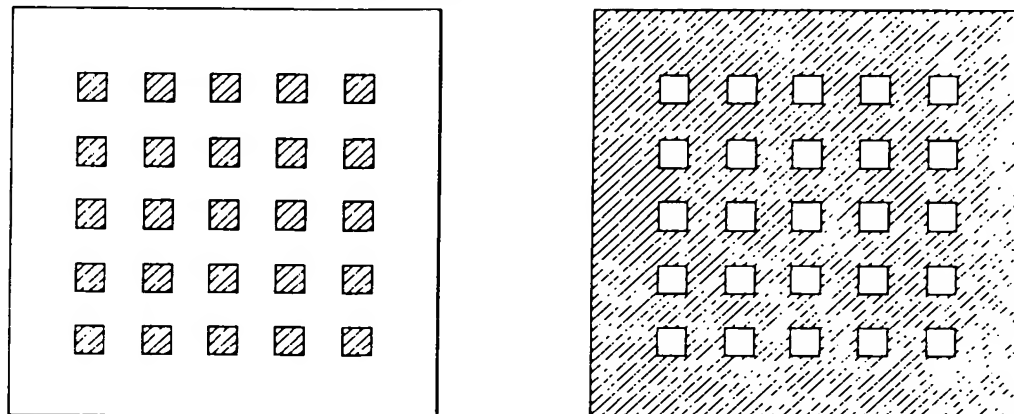
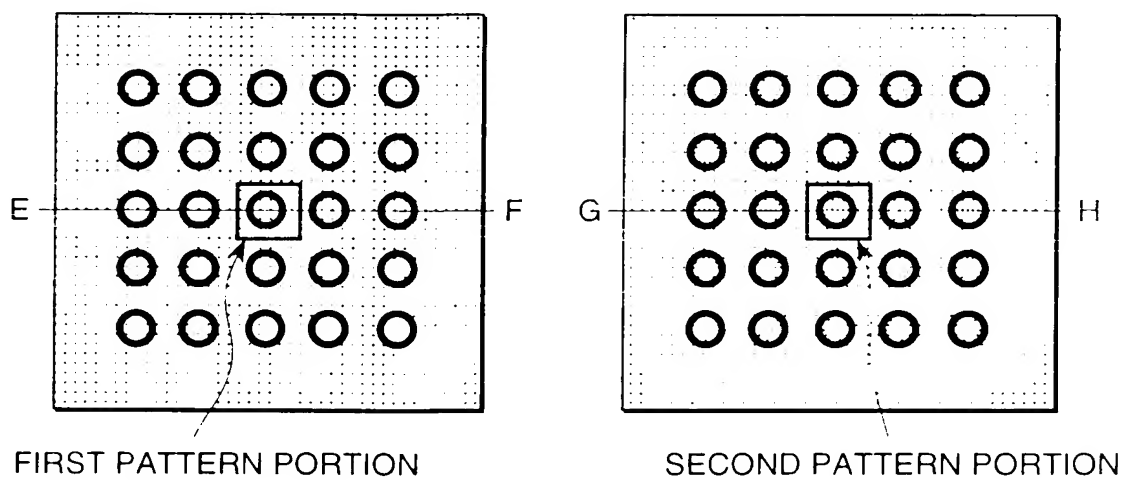
*FIG. 13(b)*

FIG. 14

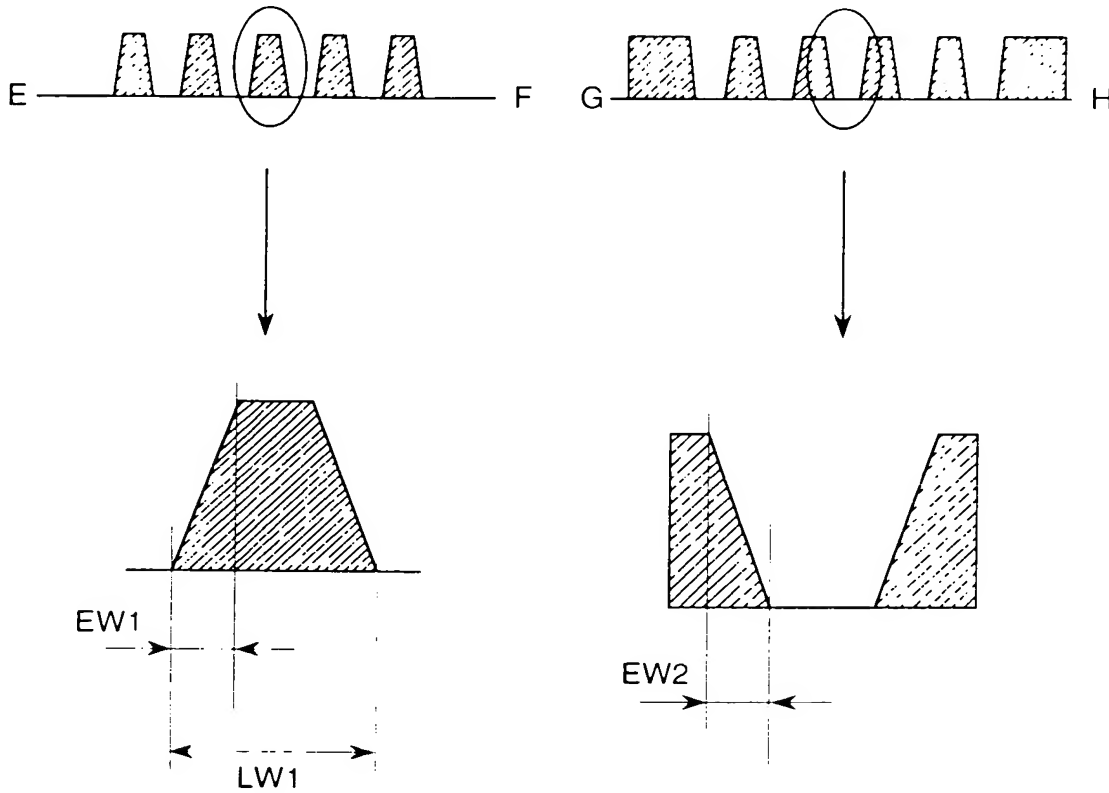
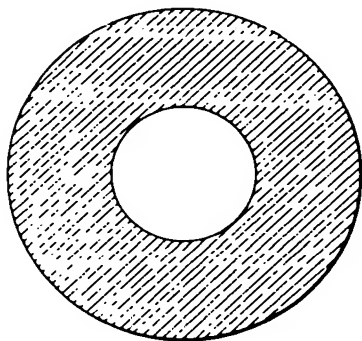


FIG. 15(a)



WHITE: TRANSMITTING PORTION
BLACK: SHIELDING PORTION

FIG. 15(b)

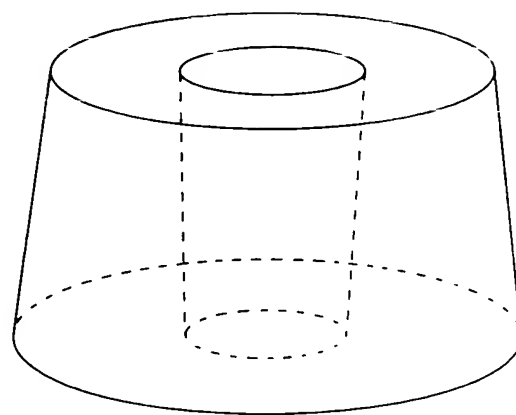


FIG. 16(a)

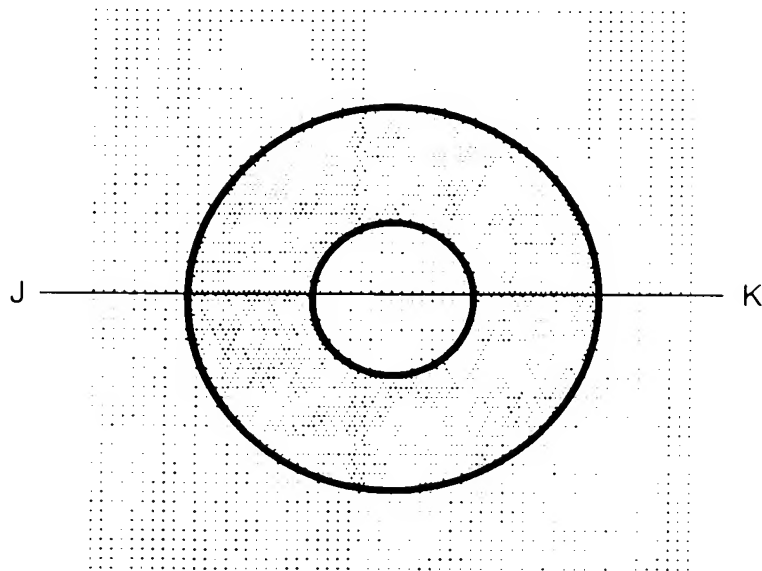


FIG. 16(b)

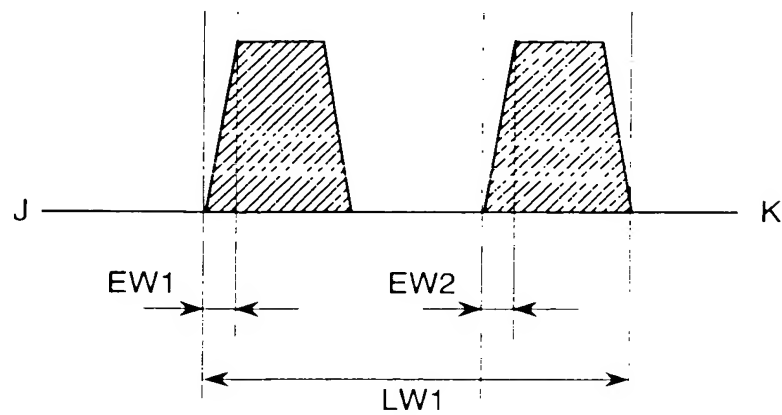
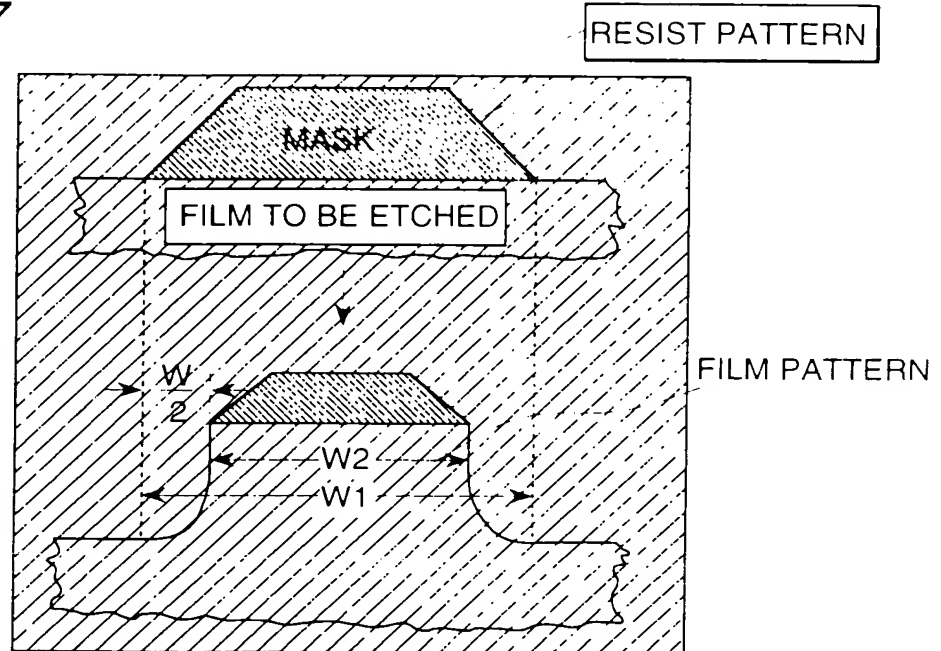


FIG. 17



W_1 : WIDTH OF THE RESIST PATTERN BOTTOM
 θ : ANGLE OF INCLINATION OF THE RESIST PATTERN
 W_2 : WIDTH OF THE FILM PATTERN

FIG. 18

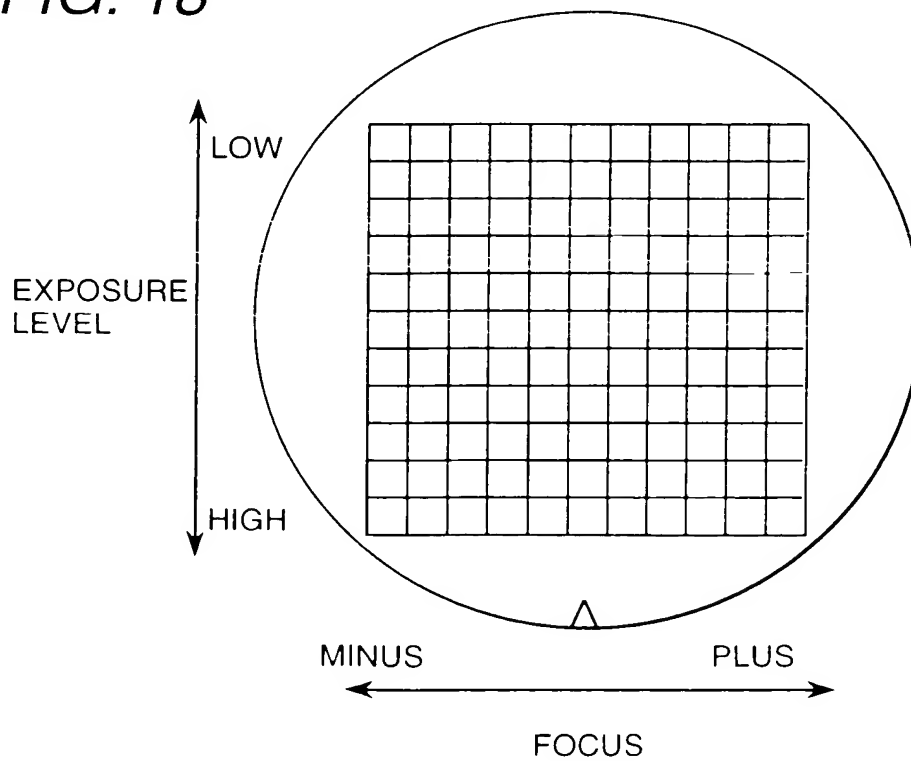
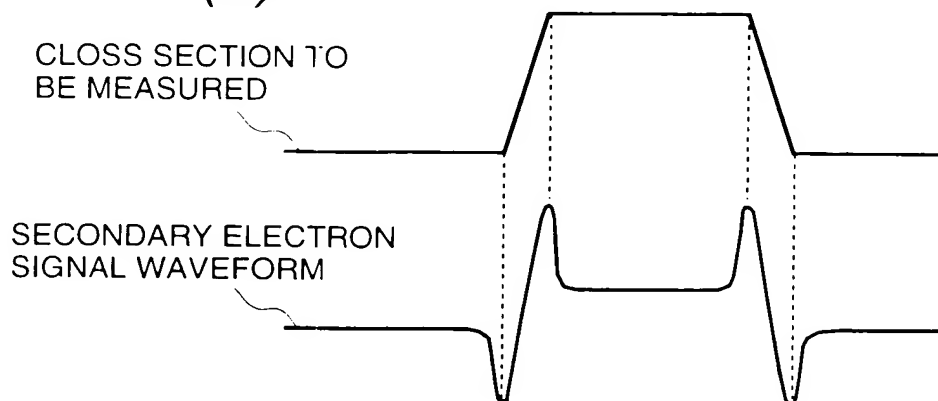
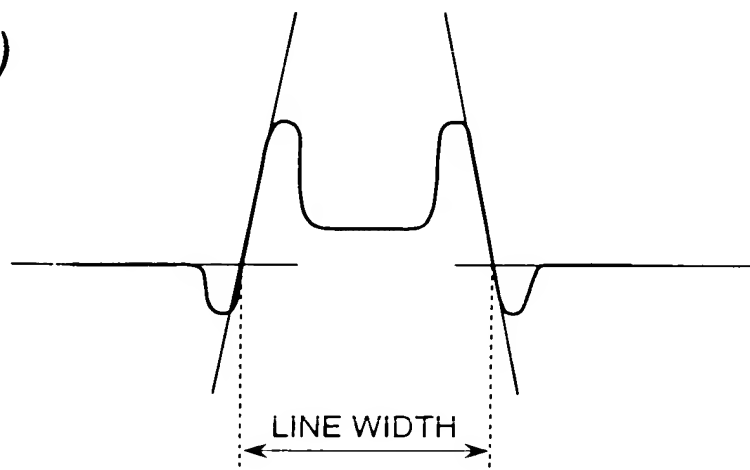
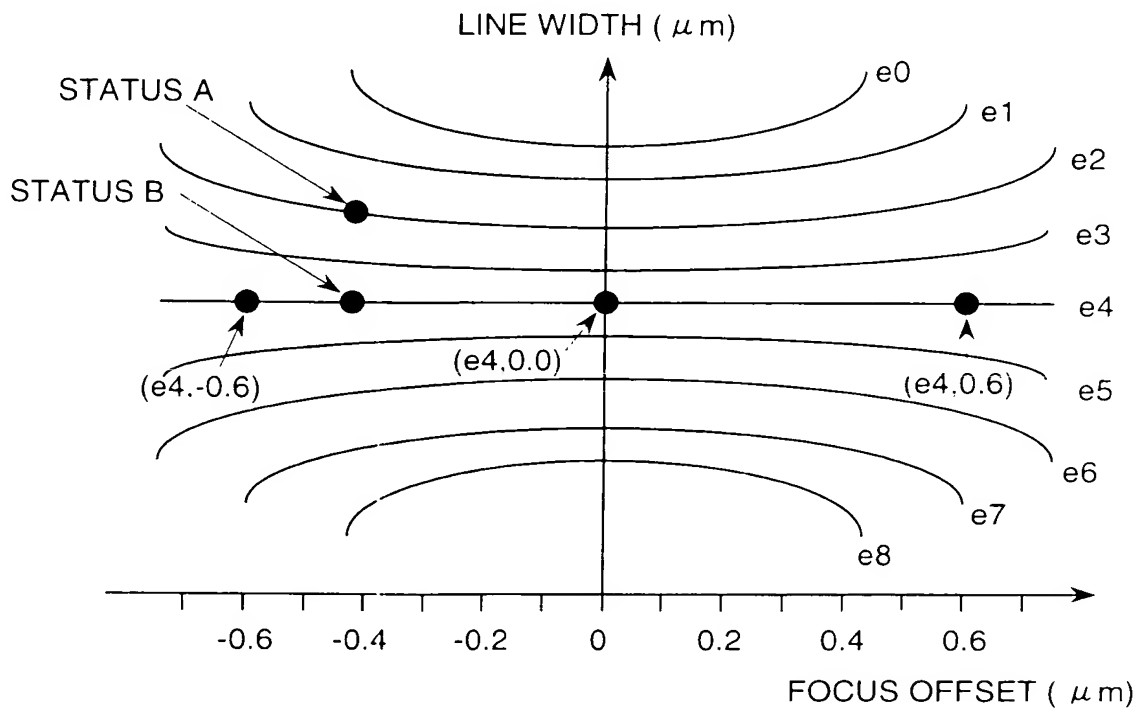


FIG. 19(a)*FIG. 19(b)**FIG. 21*

FOCUS VALUE-PULUS	OPTIMAL FOCUS	FOCUS VALUE-MINUS
<p>PHOTO RESIST</p>	<p>PHOTO RESIST</p>	<p>PHOTO RESIST</p>

FIG. 20(a)*FIG. 20(b)*